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SJ/T 10274-1991

Test methods of mask alignment and exposure system

掩模对准曝光机测试方法

(English Translation)

Issued on: November 12, 1991

Issued by: Ministry of Electronics Industry

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Document data

1 Document data

Sector: Electronics (industry standard).

Issuing body: Ministry of Electronics Industry.

Date of issue: 1991-11-12.

Date of implementation: 1992-01-01.

Status: valid.

Preview: page 2 of 2 shown, full document available. Complete English PDF, instant download:
https://chinastandards.org/standards/sj-t-10274-1991